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PATENT APPLICATION

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Date January 23, 2003

In re the Application of

Shunichi SEKI et al.

Group Art Unit: 1762

Application No.: 09/701,534

Examiner: M. Cleveland

Filed: November 30, 2000

Docket No.: 107291

For: METHOD FOR FORMING SILICON FILM AND INK COMPOSITION FOR INK JET

**LARGE ENTITY PETITION FOR 1<sup>st</sup> - 3<sup>rd</sup> EXTENSION  
OF TIME UNDER 37 C.F.R. §1.136(a) AND  
TRANSMITTAL OF FEE UNDER 37 C.F.R. §1.17**Director of the U.S. Patent and Trademark Office  
Washington, D.C. 20231

Sir:

Transmitted herewith is a response to the outstanding Official Action in the above-identified patent application. The shortened statutory period having expired October 23, 2002, an extension of time for a period of three months is hereby requested. Attached hereto is our Check No. 138352 in the amount of \$930.00 in payment for:

\_\_\_\_\_ Extension fee for response within first month pursuant to §1.136(a) (\$110.00)  
\_\_\_\_\_ Extension fee for response within second month pursuant to §1.136(a) (\$410.00)  
X Extension fee for response within third month pursuant to §1.136(a) (\$930.00)

The Director is hereby authorized to charge any additional fee or credit any overpayment associated with this communication to Deposit Account No. 15-0461. Two copies of this petition are enclosed.

Respectfully submitted,

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**DEPOSIT ACCOUNT USE  
AUTHORIZATION**

Please grant any extension  
necessary for entry;  
Charge any fee due to our  
Deposit Account No. 15-0461

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